

Special Issue

Novel Materials/Technologies for the Adsorption and Removal of Antibiotics from Aqueous Solution

Message from the Guest Editors

This Special Issue on “Novel Materials/Technologies for the Adsorption and Removal of Antibiotics from Aqueous Solution” seeks high-quality works focusing on the latest novel materials and technologies for the removal of antibiotics from water. Topics include but are not limited to:

- Novel adsorption materials (ceramic, carbon and/or composites) and performance application;
- Novel physical/chemical/biological technologies for antibiotic removal;
- Antibiotic-removal process mechanism, application, and modeling;
- Traceability and risk assessment for antibiotic contaminants.

Guest Editors

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Prof. Dr. Hao Xu

Prof. Dr. Yan Feng

Deadline for manuscript submissions

closed (31 December 2023)



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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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